

**Experiment title:**Exploration of X-rays Nano-Patterning on TiO₂**Experiment****number:**

MA-3506

Beamline:

ID16B-NA

Date of experiment:

from: 10/5/2017

to:

15/5/2017

Date of report:

02/03/2020

Shifts:

15

Local contact(s):

Damien Salomon

*Received at ESRF:***Names and affiliations of applicants** (* indicates experimentalists):M. Truccato^{1*}, V. Bonino^{1*}, L. Mino^{1*}, F. Picollo^{1*}, C. Lamberti², A. Agostino^{2*}, E. Borfecchia², C. Prestipino³¹ Department of Physics and NIS Centre, University of Turin, Turin, Italy² Department of Chemistry and NIS Centre, University of Turin, Turin, Italy³ University of Rennes 1, Equipe Chim Solide & Mat, UMR CNRS, Rennes, France.**Report:**

We have published the results corresponding to this experiment in the paper by L. Mino et al. [1].

It is well known that intense synchrotron beams can alter the state of materials, but this effect is generally considered undesired radiation damage. We have investigated the effect of local irradiation of TiO₂ rutile single crystals at ID16B-NA by means of a $56 \times 57 \text{ nm}^2$ nanobeam at 17.4 keV. Aside from a transient increase of conductivity due to a photovoltaic-like process, a nonvolatile localized change of resistance by about 4 orders of magnitude has been measured after X-ray exposure. This effect can be ascribed to the local generation of oxygen vacancies by the X-ray nanoprobe, which are subsequently ordered by the electric field applied during the acquisition of I–V curves. These results indicate that intense synchrotron beams could create oxygen vacancies in materials with tightly bound oxygen atoms, highlighting that X-ray nanoprobe could become an effective tool for oxide nanofabrication, able to locally tune the material resistivity. For instance, since the localized presence and migration of oxygen vacancies is an essential requisite for redox-based memristive devices, the possibility to locally induce oxygen vacancies could represent a novel tool for the production of oxide-based memristive devices, replacing the problematic electroforming step.

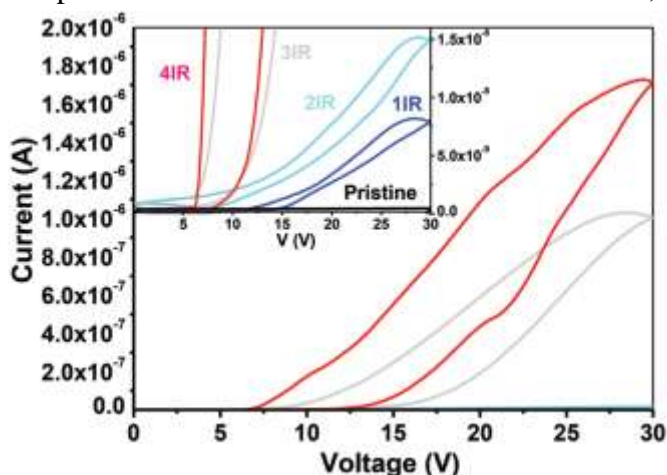


Figure 1: I–V curves acquired after each of the four X-ray irradiation steps (1IR, 2IR, 3IR, and 4IR) on an irradiation line between two Au electrodes at the maximum photon flux ($6.7 \times 10^{10} \text{ ph s}^{-1}$).

References

[1] L. Mino et al., *Adv. Electron. Mater.* **2019**, 5, 1900129.